



Cite this: *RSC Adv.*, 2017, 7, 6856

# Amorphous molybdenum sulfide on graphene–carbon nanotube hybrids as supercapacitor electrode materials

Kien-Cuong Pham,<sup>ab</sup> David S. McPhail,<sup>c</sup> Andrew T. S. Wee<sup>ad</sup> and Daniel H. C. Chua<sup>\*e</sup>

Herein, we report the application of amorphous molybdenum sulfide ( $\text{MoS}_x$ ,  $x \approx 3$ ) as the main active material for supercapacitor electrodes.  $\text{MoS}_x$  was deposited at room temperature onto a high specific surface area electrode made of graphene–carbon nanotube hybrids directly grown on carbon paper (GCNT/CP), using an electrochemical deposition method. The  $\text{MoS}_x$ /GCNT/CP electrode showed high specific capacitance. A gravimetric specific capacitance of  $414 \text{ F g}^{-1}$  was demonstrated at a constant discharge rate of  $0.67 \text{ A g}^{-1}$ . The deposition of  $\text{MoS}_x$  onto a conductive, high surface area support played a crucial role for a high specific capacitance. An up to 4.5-fold enhancement in specific capacitance was demonstrated when  $\text{MoS}_x$  was deposited on GCNT/CP as compared to  $\text{MoS}_x$  deposited on a simple carbon paper support. The  $\text{MoS}_x$ /GCNT/CP electrode is suggested to be a novel candidate for supercapacitor applications.

Received 7th December 2016  
Accepted 12th January 2017

DOI: 10.1039/c6ra27901e

[www.rsc.org/advances](http://www.rsc.org/advances)

## 1. Introduction

Renewable energy solutions are being very actively sought, due to energy security and environmental concerns. Among these, supercapacitors have recently attracted much research attention for their high power density, and quick charge/discharge capability.<sup>1–3</sup> Supercapacitors frequently make use of high surface area carbon-based materials, such as activated carbon,<sup>4</sup> graphene<sup>2,5</sup> and carbon nanotubes,<sup>6</sup> as electrode materials. However, the reported specific capacitances of carbon-based electrodes have been relatively low. Recently, other electrode materials have been actively investigated for supercapacitor applications, for example, metal oxides,<sup>7,8</sup> metal hydroxides,<sup>9,10</sup> metal sulfides,<sup>11,12</sup> to name a few. Transitional metal chalcogenides such as  $\text{WS}_2$ ,  $\text{MoS}_2$ ,  $\text{Ni}_3\text{S}_4$ ,  $\text{MoSe}_2$ , and  $\text{CuS}$  have recently emerged as promising supercapacitor electrode materials.<sup>3,11–23</sup> One notable example in this family of materials is molybdenum disulfide ( $\text{MoS}_2$ ).  $\text{MoS}_2$  is used as a supercapacitor electrode material due to its higher ionic conductivity than metal oxides

and its higher specific capacitance than graphite.<sup>3,17,18</sup> While much research attention has been paid to crystalline  $\text{MoS}_2$ ,<sup>3,12,15–18</sup> little attention has been paid to its amorphous form, except for one recent study reporting the use of amorphous  $\text{MoS}_2$  as an encapsulating material for  $\text{Ni}_3\text{S}_4$ .<sup>19</sup>

Amorphous molybdenum sulfide ( $\text{MoS}_x$ ) possesses many advantageous merits that can warrant further attention. In supercapacitors, charge storage in crystalline  $\text{MoS}_2$  can occur *via* the double layer charging on the external surface of the material or *via* the diffusion of ions into the inter-layer space of  $\text{MoS}_2$ .<sup>14,17,18</sup> The diffusion of ions into the inter-layer space occurs through the open edge sites of  $\text{MoS}_2$ , due to the anisotropic layered structure of crystalline  $\text{MoS}_2$ . Naturally occurring crystalline  $\text{MoS}_2$  has a layered crystal structure similar to graphite. To enhance this diffusion process, Soon and Loh strategically oriented the open edge planes of  $\text{MoS}_2$  to maximize the availability of these “entry” sites.<sup>14</sup> In contrast, the amorphous form of materials generally has more open and isotropic atomic structures.<sup>24</sup> The diffusion of ions in  $\text{MoS}_x$  is therefore not limited by the availability of edge sites. The diffusion of ions may happen throughout the entire material surface. The diffusion coefficient of ions (e.g. lithium) in  $\text{MoS}_x$  was found to be several orders of magnitude higher than that in crystalline  $\text{MoS}_2$ .<sup>24,25</sup> The electrical conductivity of  $\text{MoS}_x$  was also found to be two orders of magnitude higher than that of crystalline  $\text{MoS}_2$ .<sup>24</sup> The higher electronic conductivity of  $\text{MoS}_x$  is beneficial for a better supercapacitive performance. Furthermore, in layered materials such as graphene and  $\text{MoS}_2$ , it was suggested that edge sites and defect sites in the material structures were more electro-active than the basal plane atoms and can enhance electrode capacitance.<sup>26</sup>  $\text{MoS}_x$  intrinsically contains abundance

<sup>a</sup>NUS Graduate School for Integrative Sciences and Engineering (NGS), National University of Singapore, 28 Medical Drive, Singapore 117456, Singapore. E-mail: [phamkienkuong@u.nus.edu](mailto:phamkienkuong@u.nus.edu)

<sup>b</sup>Department of Materials, Imperial College London, Exhibition Road, London SW7 2AZ, UK

<sup>c</sup>Department of Chemistry and Biochemistry, University of Texas at Dallas, TX 75080-3021, USA. E-mail: [dsm160330@utdallas.edu](mailto:dsm160330@utdallas.edu)

<sup>d</sup>Department of Physics, National University of Singapore, 2 Science Drive 3, Singapore 117542, Singapore. E-mail: [phyweets@nus.edu.sg](mailto:phyweets@nus.edu.sg)

<sup>e</sup>Department of Materials Science and Engineering, National University of Singapore, 9 Engineering Drive 1, Singapore 117576, Singapore. E-mail: [msechcd@nus.edu.sg](mailto:msechcd@nus.edu.sg); Fax: +65-6776-3604; Tel: +65-6516-8933



of defect sites. The contribution of defect sites in MoS<sub>x</sub> to the total capacitance is non-trivial and deserves further attention. As an additional advantage, MoS<sub>x</sub> syntheses can be routinely done at ambient temperature using wet chemical syntheses<sup>27,28</sup> or electrodeposition methods,<sup>29,30</sup> in contrast to the higher temperature syntheses of crystalline MoS<sub>2</sub>. Herein, we investigate molybdenum sulfide in its amorphous form as the main active supercapacitor material.

Although molybdenum sulfide materials potentially have higher specific capacitance than graphite, they are generally less electronically conductive than graphitic materials.<sup>3</sup> The poor electronic conductivity of molybdenum sulfide could result in low material utilization and poor high-discharge-rate performance. Depositing MoS<sub>x</sub> on a high surface area conductive support can be an effective approach to enhance the electron transport between the active material and the current collector, and therefore maximize the electrode capacitance.

In our previous studies, we reported a hierarchical electrode structure of graphene-carbon nanotube hybrids grown directly on carbon paper (GCNT/CP).<sup>31–35</sup> In this structure, CNTs were firstly grown on Toray carbon paper, and free-standing graphene was then grown directly on CNT scaffolds. The electrode had an integrated, binder-free, high specific surface area, and conductive structure. MoS<sub>x</sub> was also successfully deposited on the GCNT/CP support for the Hydrogen Evolution Reaction (HER) application in our previous study, reporting one of the most active molybdenum sulfide-based HER catalysts to date.<sup>33</sup> Herein, the supercapacitive properties of MoS<sub>x</sub> and specific capacitance enhancement effects of the MoS<sub>x</sub>/GCNT/CP electrode will be reported.

## 2. Experimental

### 2.1. Growth of the GCNT hybrids

The GCNT hybrids were grown on carbon paper using the Chemical Vapor Deposition (CVD) methods in a two-step procedure. The details of growth procedure and the hybrid structures have been previously reported elsewhere.<sup>31,32,34</sup> To summarize, CNTs were firstly grown on a carbon paper substrate using the thermal CVD technique. Subsequently, free-standing graphene was grown on the CNT scaffolds using the catalyst-free radio frequency plasma enhanced CVD.

### 2.2. Deposition of MoS<sub>x</sub> on the GCNT/CP support

MoS<sub>x</sub> was deposited onto the GCNT/CP electrode using an electrodeposition method as previously reported.<sup>33</sup> To summarize, MoS<sub>x</sub> was firstly electrodeposited on the GCNT/CP support from a 20 mM aqueous solution of ammonium tetrathiomolybdate ((NH<sub>4</sub>)<sub>2</sub>MoS<sub>4</sub> 99.97%, Sigma-Aldrich), performed in a three-electrode electrochemical cell. The deposition was carried out by holding the GCNT/CP working electrode at 0.7 V *vs.* Standard Hydrogen Electrode (SHE) potential. Subsequently, the MoS<sub>x</sub>-deposited GCNT/CP electrode underwent 10 reductive potential sweeps from 0.2 to -0.5 V *vs.* SHE in a 0.5 M H<sub>2</sub>SO<sub>4</sub> electrolyte solution. In a typical experiment, the final MoS<sub>x</sub> loading was approximately 3 mg cm<sup>-2</sup>. In all subsequent

discussions, MoS<sub>x</sub>/GCNT/CP refers to this final condition of the electrode. For comparisons, MoS<sub>x</sub> was also deposited onto a carbon paper substrate (MoS<sub>x</sub>/carbon paper) using the same aforementioned procedure and MoS<sub>x</sub> loading of 3 mg cm<sup>-2</sup>.

### 2.3. Material characterization

The morphological characterization of the GCNT/CP and MoS<sub>x</sub>/GCNT/CP electrodes was performed with Field Emission Scanning Electron Microscopy (FE-SEM, JEOL JSM-6700F). The chemical analyses were characterized with X-ray Photoelectron Spectroscopy (XPS) (Omicron 7-channeltron analyzer, Al K<sub>α</sub> X-ray source of 1486.7 eV photon energy, Omicron X-ray twin anode source). Constant analyzer energy (CAE) mode of 20 eV pass energy was used for high resolution scans. The amorphous nature of MoS<sub>x</sub> was assessed by Raman spectroscopy (Renishaw inVia Raman microscope, 532 nm laser) and X-ray diffraction (XRD) (Philips X'Pert, Cu K<sub>α</sub> (λ = 1.54 Å) source).

### 2.4. Electrochemical measurements

Supercapacitive properties of the MoS<sub>x</sub>/GCNT/CP electrode were measured in a three-electrode cell configuration. The MoS<sub>x</sub>/GCNT/CP electrode was used as working electrode. A platinum rod, a Ag/AgCl (3 M KCl) electrode and a 1 M Na<sub>2</sub>SO<sub>4</sub> solution were used as counter electrode, reference electrode and electrolyte, respectively. The neutral 1 M Na<sub>2</sub>SO<sub>4</sub> electrolyte was used instead of acidic H<sub>2</sub>SO<sub>4</sub> electrolyte to avoid the hydrogen evolution process. The MoS<sub>x</sub>/GCNT/CP electrode has been shown to be highly active towards HER in acidic electrolyte in our previous study.<sup>33</sup> All electrodepositions and electrochemical measurements were carried out with an Autolab PGSTAT302N potentiostat/galvanostat (Metrohm), fitted with a FRA2.V10 frequency response analyzer and a SCANGEN analog scan generator. All potentials in the following contexts were reported against SHE. Cyclic voltammetry and galvanostatic charge/discharge experiments were carried out in a potential window of between -0.5 and 0.3 V *vs.* SHE. Electrochemical Impedance Spectroscopy (EIS) was measured at -0.1 V *vs.* SHE in a frequency range of between 10 kHz and 0.01 Hz with an AC perturbation voltage of 5 mV. Stability testing was performed using 500 galvanostatic charge/discharge cycles at a constant charge/discharge rate of 5 A g<sup>-1</sup>.

## 3. Results and discussion

### 3.1. Physical properties of the GCNT hybrids and the MoS<sub>x</sub>/GCNT/CP electrode

The morphological study with FE-SEM of the GCNT/CP and MoS<sub>x</sub>/GCNT/CP electrodes is provided in Fig. 1. Fig. 1a shows an SEM micrograph of the GCNT/CP support. The porous and high surface area structure of the GCNT/CP support was clearly observed. The GCNT hybrids possessed a unique morphology with high density of free-standing graphene deposited on the fibrous CNT scaffolds. The CNT scaffolds have two main roles in the GCNT/CP electrode structure. Firstly, as opposed to regular two-dimensional graphene sheets which have tendency to restack and block the mass transport pathways, CNTs provide



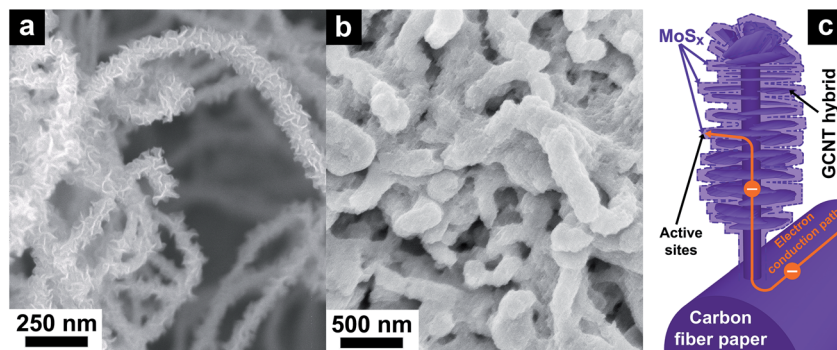


Fig. 1 Morphological characterization with FE-SEM of (a) the GCNT/CP support, and (b) the MoS<sub>x</sub>/GCNT/CP electrode. (c) Schematic illustration of the MoS<sub>x</sub>/GCNT/CP electrode structure.

a porous overall electrode structure. Such a porous electrode structure could better facilitate the permeation of electrolyte solution towards the active material of MoS<sub>x</sub>. Secondly, the direct growth of CNTs on carbon paper can provide better mechanical integrity and more direct electrical conducting paths. The porous and high surface area structure of the GCNT hybrids could facilitate the deposition of MoS<sub>x</sub> with good material dispersion, good electron and electrolytic ion transport. Further characterization of the GCNT/CP support with TEM, Raman spectroscopy, and XPS can be found in our previous study.<sup>31</sup> Fig. 1b shows an SEM micrograph of the MoS<sub>x</sub>/GCNT/CP electrode. MoS<sub>x</sub> was successfully deposited on the high specific surface area GCNT/CP support. MoS<sub>x</sub> was found to coat and disperse well on the conductive support, which is highly beneficial for the enhanced electron transport towards the active material MoS<sub>x</sub>. A schematic illustration of the MoS<sub>x</sub>/GCNT/CP electrode structure is shown in Fig. 1c.

The chemical state of MoS<sub>x</sub> was assessed with XPS. Fig. 2a shows the high resolution XPS scan in the S 2p region of spectrum. The spectrum was deconvoluted into two doublets. The S<sup>(A)</sup> 2p doublet at Binding Energy (BE) of 162.9–164.1 eV was assigned to apical S<sup>2-</sup> or bridging S<sub>2</sub><sup>2-</sup>.<sup>36</sup> The S<sup>(B)</sup> 2p doublet at BE of 161.4–162.6 eV was assigned to basal plane S<sup>2-</sup> or terminal S<sub>2</sub><sup>2-</sup>.<sup>36</sup> Fig. 2b shows the high resolution XPS scan in the Mo 3d–S 2s region. The spectrum was deconvoluted into four peak sets, including two S 2s peaks at BE of 227.3 and 226.1 eV, corresponding to the respective S<sup>(A)</sup> and S<sup>(B)</sup> chemical states, a Mo<sup>(A)</sup> 3d doublet at BE of 231.85–235.0 eV, and a Mo<sup>(B)</sup> 3d doublet at BE of 229.3–232.45 eV. The Mo<sup>(A)</sup> doublet was attributed to Mo<sup>5+</sup> chemical state<sup>28</sup> or Mo<sup>4+</sup> as in molybdenum oxysulfide MoS<sub>x</sub>O<sub>y</sub>.<sup>30,37</sup> The Mo<sup>(B)</sup> doublet was attributed to Mo<sup>4+</sup> as in MoS<sub>2</sub> or MoS<sub>3</sub>.<sup>37</sup> Both Mo and S appeared in mixed chemical states and in good agreement with reported XPS spectra of amorphous MoS<sub>3</sub>.<sup>36</sup> As opposed to the XPS spectra of MoS<sub>x</sub>/GCNT/CP, typical XPS spectra of crystalline MoS<sub>2</sub> only show Mo<sup>(B)</sup> and S<sup>(B)</sup> chemical states. Using XPS spectra of crystalline MoS<sub>2</sub> as references, the stoichiometry of MoS<sub>x</sub> was found as Mo : S = 1 : 3.09.

The amorphous nature of MoS<sub>x</sub> was further examined with Raman spectroscopy and XRD. Fig. 3a shows the Raman spectrum of the MoS<sub>x</sub>/GCNT/CP electrode. As opposed to crystalline

MoS<sub>2</sub> of which the Raman spectrum typically shows characteristic peaks E<sub>2g</sub><sup>1</sup> and A<sub>1g</sub>, the Raman spectrum of the as-deposited MoS<sub>x</sub> showed broad peaks with Raman shift of between 200 and

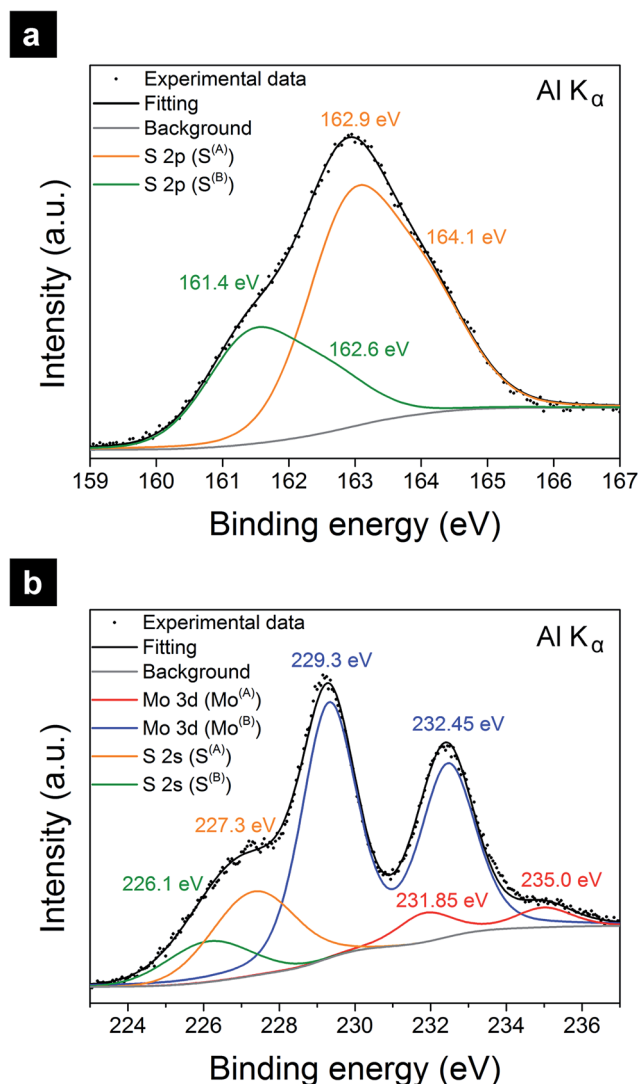


Fig. 2 Chemical analysis of the MoS<sub>x</sub>/GCNT/CP electrode with XPS in (a) S 2p, and (b) Mo 3d–S 2s regions.



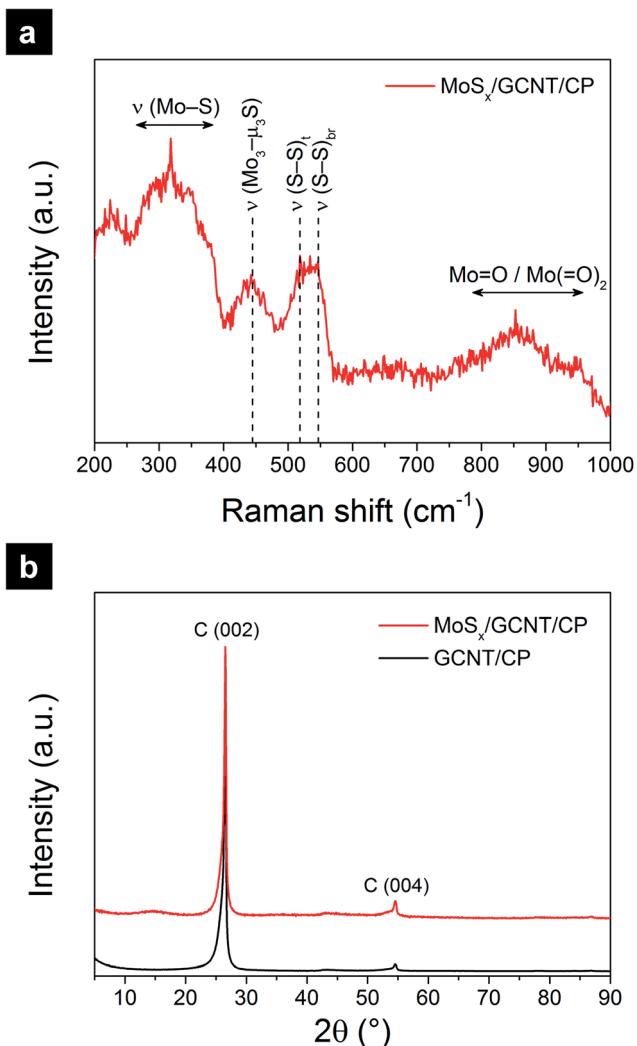


Fig. 3 Crystallinity analyses of the MoS<sub>x</sub>/GCNT/CP electrode with (a) Raman spectroscopy, and (b) XRD.

1000 cm<sup>-1</sup>. The spectrum was in good agreement with previously reported Raman spectra of amorphous molybdenum sulfide materials.<sup>36,38,39</sup> The Raman peaks at ~550 and ~520 cm<sup>-1</sup> were assigned to the vibration modes of bridging S<sub>2</sub><sup>2-</sup> (ν(S-S)<sub>br</sub>) and terminal S<sub>2</sub><sup>2-</sup> (ν(S-S)<sub>t</sub>), respectively.<sup>39</sup> The Raman peaks at ~270–380 cm<sup>-1</sup> and ~445 cm<sup>-1</sup> were assigned to molybdenum sulfide vibration modes of ν(Mo-S) and ν(Mo<sub>3</sub>-μ<sub>3</sub>S), respectively.<sup>39</sup> The pronounced vibration modes of bridging and terminal S<sub>2</sub><sup>2-</sup> as well as apical sulfide center were characteristic for the amorphous nature of the as-deposited MoS<sub>x</sub>. The Raman peaks at ~800–950 cm<sup>-1</sup> was assigned to molybdenum oxide defects,<sup>39</sup> suggesting the possible presence of molybdenum oxysulfide MoS<sub>x</sub>O<sub>y</sub>. The possible presence of MoS<sub>x</sub>O<sub>y</sub> was also evident by the Mo<sup>(A)</sup> state in the XPS analysis. To further probe the amorphous nature of MoS<sub>x</sub>, XRD measurements were performed on the GCNT/CP and MoS<sub>x</sub>/GCNT/CP electrodes. The resulting XRD spectra are shown in Fig. 3b. Both spectra showed sharp and strong characteristic peaks of graphitic carbon (002) plane, and therefore indicated

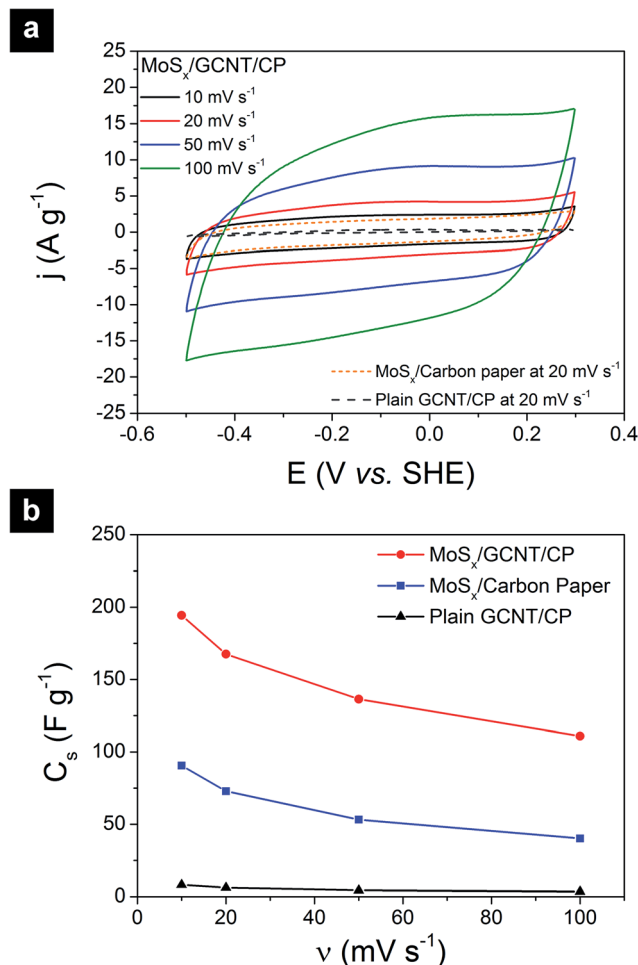


Fig. 4 Supercapacitive performance of electrodes assessed by cyclic voltammetry. (a) Cyclic voltammograms of the MoS<sub>x</sub>/GCNT/CP electrode at different scan rates from 10 to 100 mV s<sup>-1</sup>, of the bare GCNT/CP support and MoS<sub>x</sub>/carbon paper electrode at 20 mV s<sup>-1</sup> scan rate. (b) The dependence of electrode specific capacitance on scan rate.

the high crystallinity of the GCNT/CP support. The XRD spectrum of MoS<sub>x</sub>/GCNT/CP did not show any strong additional characteristic peaks that could otherwise suggest the presence of crystalline MoS<sub>2</sub>, except very weak and broad diffraction bands of 2θ from 10° to 20° and from 30° to 40°. The XRD result further indicated the amorphous nature of the deposited MoS<sub>x</sub>.

### 3.2. Supercapacitive properties of the MoS<sub>x</sub>/GCNT/CP electrode

The supercapacitive properties of MoS<sub>x</sub>/GCNT/CP electrode were assessed with cyclic voltammetry and galvanostatic charge/discharge. Fig. 4a shows the cyclic voltammograms of MoS<sub>x</sub>/GCNT/CP electrode obtained at scan rates of 10, 20, 50, and 100 mV s<sup>-1</sup>. For reference purposes, the cyclic voltammograms of bare GCNT/CP support and of MoS<sub>x</sub>/carbon paper were also recorded. However, for a clearer presentation, only the cyclic voltammograms obtained at the scan rate of 20 mV s<sup>-1</sup> were plotted for these two reference samples. It should be noted that, while the bare GCNT/CP sample did not contain any MoS<sub>x</sub>, in



order to present the contribution of the GCNT/CP support to the overall capacitance of MoS<sub>x</sub>/GCNT/CP, the cyclic voltammograms of the bare GCNT/CP were also normalized for a hypothetical MoS<sub>x</sub> loading of 3 mg cm<sup>-2</sup>. The cyclic voltammograms of MoS<sub>x</sub>/GCNT/CP appeared quasi-rectangular. The quasi-rectangular shape was retained even at a high scan rate of 100 mV s<sup>-1</sup>, which suggested a good high-scan-rate capacitive performance of the MoS<sub>x</sub>/GCNT/CP electrode. The MoS<sub>x</sub>/GCNT/CP electrode showed much higher current density *j* than that of the GCNT/CP support and of the MoS<sub>x</sub>/carbon paper electrode.

The gravimetric specific capacitance of electrodes was calculated as following:

$$C_s = \frac{\int j(E)dE}{2v\Delta E}$$

in which *C<sub>s</sub>* is the gravimetric specific capacitance of electrode (in F g<sub>MoS<sub>x</sub></sub><sup>-1</sup>), *j*(*E*) is the instantaneous gravimetric current density (in A g<sub>MoS<sub>x</sub></sub><sup>-1</sup>), *v* is the scan rate (in V s<sup>-1</sup>), Δ*E* is the scanned potential window of 0.8 V. ∫*j*(*E*)*dE* is the integral area enclosed by the cyclic voltammograms.

The calculated *C<sub>s</sub>* of electrodes based on cyclic voltammetry are summarized in Fig. 4b. The MoS<sub>x</sub>/GCNT/CP electrode demonstrated a capacitance of 194 F g<sup>-1</sup> at the scan rate of 10 mV s<sup>-1</sup> and retained a capacitance of 111 F g<sup>-1</sup> at a high scan rate of 100 mV s<sup>-1</sup>. The capacitive contribution from the GCNT/CP support to the total capacitance of the MoS<sub>x</sub>/GCNT/CP electrode was minimal (e.g. 8.2 F g<sup>-1</sup> at the scan rate of 10 mV s<sup>-1</sup>). MoS<sub>x</sub>/carbon paper showed much lower capacitance than that of the MoS<sub>x</sub>/GCNT/CP electrode. MoS<sub>x</sub>/carbon paper showed a capacitance of 91 F g<sup>-1</sup> at the scan rate of 10 mV s<sup>-1</sup> and a capacitance of 40 F g<sup>-1</sup> at the scan rate of 100 mV s<sup>-1</sup>. The reported capacitance values were 2–3 times lower than those of the MoS<sub>x</sub> deposited on the high surface area GCNT/CP support. In this work, both MoS<sub>x</sub>/GCNT/CP and MoS<sub>x</sub>/carbon paper samples were prepared using the same MoS<sub>x</sub> deposition protocol. As such, the specific capacitance enhancement in the MoS<sub>x</sub>/GCNT/CP as compared to MoS<sub>x</sub>/carbon paper was attributed to the enhanced dispersion of MoS<sub>x</sub>, better access to the electrolyte, and more efficient electron transport, resulted from a much higher specific surface area of the GCNT/CP support. Comparisons of the specific surface area of GCNT/CP and carbon paper supports have been reported in detail in our previous work.<sup>33</sup> As reported in our previous work, the GCNT/CP support had ≈50 times higher roughness factor (the ratio between the microscopic extended surface area and the electrode projected surface area) compared to the simple carbon paper support.<sup>33</sup> The deposition of MoS<sub>x</sub> on a high surface area conductive support demonstrated this to be an effective method to enhance the electrode capacitance.

The specific capacitance of MoS<sub>x</sub> can also be characterized with galvanostatic charge/discharge curves, as shown in Fig. 5. Fig. 5a shows the galvanostatic charge/discharge curves of the MoS<sub>x</sub>/GCNT/CP electrode, measured at different charge/discharge rates from 0.67 to 16.7 A g<sup>-1</sup>. The charge/discharge curves were quasi-triangular at the low charge/discharge rate of 0.67 A g<sup>-1</sup> and became more symmetric and triangular at

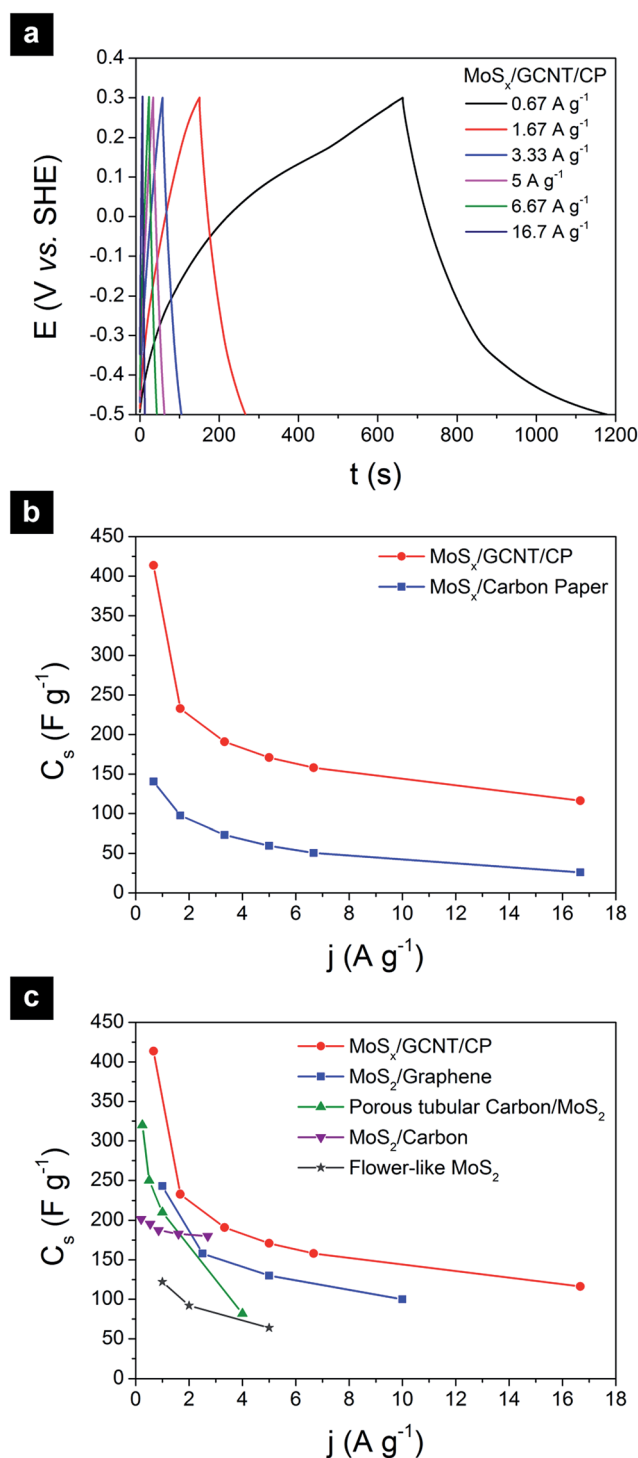


Fig. 5 Supercapacitive performance of electrodes assessed by galvanostatic charge/discharge curves. (a) Charge/discharge curves of the MoS<sub>x</sub>/GCNT/CP electrode obtained at different charge/discharge rates from 0.67 to 16.7 A g<sup>-1</sup>. (b) The dependence of electrode specific capacitance on charge/discharge rate. (c) A comparison of the discharge capacitance of MoS<sub>x</sub>/GCNT/CP against crystalline MoS<sub>2</sub>-based electrode materials reported in the literature.

higher charge/discharge rates. The gravimetric specific discharge capacitance of MoS<sub>x</sub>/GCNT/CP based on the charge/discharge curves was calculated as following:



$$C_s = \frac{j\Delta t}{\Delta E}$$

in which  $C_s$  is the gravimetric specific discharge capacitance of electrode (in  $F g_{\text{MoS}_x}^{-1}$ ),  $j$  is the gravimetric galvanostatic discharge rate (in  $A g_{\text{MoS}_x}^{-1}$ ),  $\Delta t$  is the discharge time (in s),  $\Delta E$  is the charge/discharge potential window of 0.8 V.

The calculated  $C_s$  of electrodes based on galvanostatic charge/discharge curves are summarized in Fig. 5b. The  $\text{MoS}_x/\text{GCNT}/\text{CP}$  electrode demonstrated a remarkable discharge capacitance of  $414 F g^{-1}$  at the discharge rate of  $0.67 A g^{-1}$ . The  $\text{MoS}_x/\text{GCNT}/\text{CP}$  electrode retained a high discharge capacitance of  $116 F g^{-1}$  even at a high discharge rate of  $16.7 A g^{-1}$ . Similar to the cyclic voltammetry experiments, the  $\text{MoS}_x/\text{carbon}$  paper electrode once again showed much lower specific capacitance than that of the  $\text{MoS}_x/\text{GCNT}/\text{CP}$  electrode, with  $C_s$  of 140 and  $26 F g^{-1}$  at discharge rates of  $0.67$  and  $16.7 A g^{-1}$ , respectively. A 3–4.5 fold enhancement factor in specific capacitance was demonstrated by  $\text{MoS}_x/\text{GCNT}/\text{CP}$  as compared to  $\text{MoS}_x/\text{carbon}$  paper. The strongly enhanced specific capacitance of  $\text{MoS}_x$  when being deposited on a high surface area support was once again demonstrated through the galvanostatic charge/discharge experiments.

With the specific capacitance of  $414 F g^{-1}$  obtained at the discharge rate of  $0.67 A g^{-1}$ , the  $\text{MoS}_x/\text{GCNT}/\text{CP}$  electrode demonstrated a significant improvement in specific capacitance over that of carbon-based supercapacitor electrode materials.<sup>40,41</sup> Although the demonstrated capacitance was lower than the best-in-class capacitance demonstrated by hydrous ruthenium oxide ( $\text{RuO}_2 \cdot x\text{H}_2\text{O}$ ),<sup>42,43</sup>  $\text{MoS}_x$  has the advantages of low material cost and simple room-temperature synthesis. The high cost of precious metal in  $\text{RuO}_2$  has been preventing the material from practical applications despite the high supercapacitive performance. Fig. 5c shows a comparison of discharge capacitance of the  $\text{MoS}_x/\text{GCNT}/\text{CP}$  electrode with examples of crystalline  $\text{MoS}_2$ -based electrode materials reported in the literature, including  $\text{MoS}_2/\text{graphene}$ ,<sup>17</sup> porous tubular carbon/ $\text{MoS}_2$ ,<sup>13</sup>  $\text{MoS}_2/\text{carbon}$  composite,<sup>44</sup> and flower-like  $\text{MoS}_2$  nanospheres.<sup>45</sup> The  $\text{MoS}_x/\text{GCNT}/\text{CP}$  electrode consistently showed better high-discharge-rate capacitance than the crystalline  $\text{MoS}_2$  materials, in which their capacitances decreased rapidly at higher discharge current densities.

The higher capacitance at high discharge rates of the  $\text{MoS}_x/\text{GCNT}/\text{CP}$  electrode could be due to the faster ion diffusion in  $\text{MoS}_x$  as compared to crystalline  $\text{MoS}_2$  and/or the good electron and electrolytic ion transport in the  $\text{MoS}_x/\text{GCNT}/\text{CP}$  electrode.

Table 1 provides a comparison for the specific capacitance of the  $\text{MoS}_x/\text{GCNT}/\text{CP}$  electrode against other representative supercapacitor materials reported in the literature. Due to the large variety of specific material approaches, the specific capacitance of materials other than  $\text{MoS}_x$  and  $\text{MoS}_2$ -based materials were presented by the typical range of specific capacitance reported in the literature.

Coulombic efficiency during charge/discharge cycles of the  $\text{MoS}_x/\text{GCNT}/\text{CP}$  electrode started at relatively modest values of between 77% and 87%—depending on the charge/discharge rate—in the first charge/discharge cycle. However, the coulombic efficiency of the electrode quickly reached above 97% after 10 charge/discharge cycles, and above 99% after 25 charge/discharge cycles at  $5 A g^{-1}$ .

For a better understanding of the electrode interfacial properties, EIS was performed at  $-0.1 V$  vs. SHE. EIS spectra of the  $\text{MoS}_x/\text{GCNT}/\text{CP}$  and  $\text{MoS}_x/\text{carbon}$  paper electrodes were analyzed with equivalent circuit fitting. The EIS spectra and fitting curves of the electrodes are shown in Fig. 6. Fig. 6a and b show the EIS spectra and fitting curves presented in Nyquist plot and Bode plots, respectively. The Nyquist plots of the  $\text{MoS}_x/\text{GCNT}/\text{CP}$  and  $\text{MoS}_x/\text{carbon}$  paper electrodes showed nearly vertical curves, which suggested nearly idealistic capacitive behaviors of the electrodes. The equivalent circuit used for all fittings is presented in Fig. 6c. In this circuit,  $L_{\text{cab}}$  represents a parasitic inductance due to connecting cables or instruments. A minor inductive response was observed at the high frequency of  $\sim 10^4$  Hz.  $R_{\text{ohm}}$  represents the ohmic resistance contributed by the uncompensated electrolyte resistance and internal resistance of electrode.  $R_{\text{con}}$  and  $C_{\text{con}}$  represent contact resistance and contact capacitance, respectively. The contact resistance and contact capacitance account for the small arc at high frequency range of  $\sim 10^3$  Hz.  $R_{\text{ct}}$ ,  $W$ , and  $\text{CPE}_{\text{dl}}$  represent the charge transfer resistance, Warburg diffusion impedance, and electrical double layer capacitance constant phase element,

**Table 1** Comparison for the specific capacitance of the  $\text{MoS}_x/\text{GCNT}/\text{CP}$  electrode against the reported literature

Electrode material	Typical range of specific capacitance ( $F g^{-1}$ )	References
Activated carbon	115–340	46–48
Purified CNTs	20–80	49 and 50
Graphene, reduced graphene oxide	135–205	2 and 51
Hydrous $\text{RuO}_2$	720–1300	42 and 52–54
$\text{MnO}_2$	195–350	55–57
Conductive polymers	230–1030	58–63
$\text{MoS}_x/\text{GCNT}/\text{CP}$	414 (at $0.67 A g^{-1}$ )	This study
$\text{MoS}_2/\text{graphene}$	243 (at $1 A g^{-1}$ )	17
Porous tubular carbon/ $\text{MoS}_2$	250 (at $0.5 A g^{-1}$ )	13
$\text{MoS}_2/\text{carbon}$	195 (at $0.54 A g^{-1}$ )	44
Flower-like $\text{MoS}_2$	122 (at $1 A g^{-1}$ )	45
1T- $\text{MoS}_2$	$\sim 100$ (at $20 mV s^{-1}$ )	12



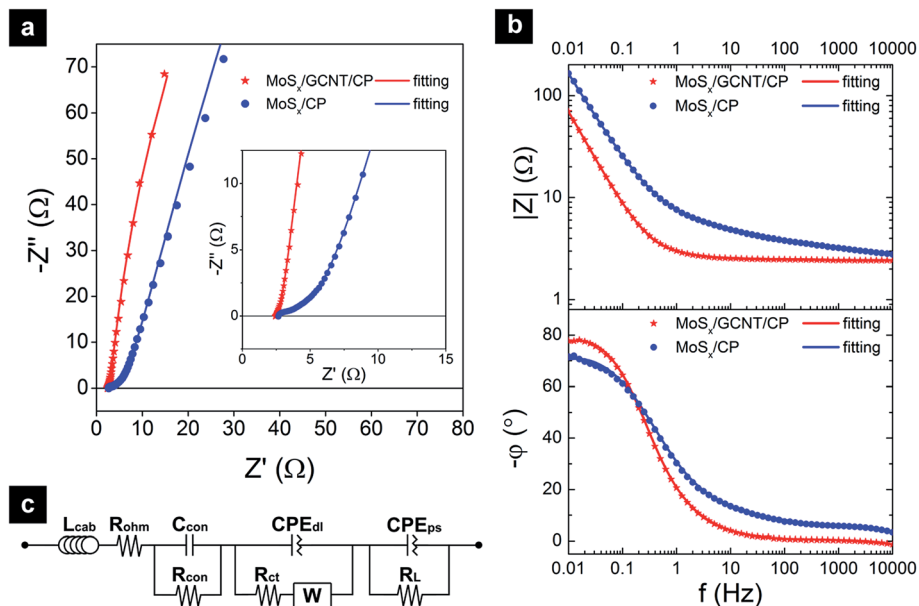


Fig. 6 EIS spectra and equivalent circuit fittings of the MoS<sub>x</sub>/GCNT/CP and MoS<sub>x</sub>/carbon paper electrodes presented in (a) Nyquist plot with (inset) the closed up view at high frequency region, and (b) Bode plots. (c) Equivalent circuit used for all fittings in (a, b).

respectively.  $R_L$  and  $CPE_{ps}$  are leak resistance and pseudo-capacitance constant phase element, respectively. Equivalent circuit fitting results showed that MoS<sub>x</sub>/GCNT/CP demonstrated a much faster charge transfer kinetic ( $R_{ct} = 0.352 \Omega \text{ cm}^2$ ) as compared to MoS<sub>x</sub> deposited on carbon paper ( $R_{ct} = 4.850 \Omega \text{ cm}^2$ ). The enhancement in charge transfer kinetic (13.8 times smaller  $R_{ct}$ ) was most likely attributed to the effective material dispersion and efficient electron transport towards MoS<sub>x</sub> provided by the GCNT/CP support. Similar enhancement in kinetic was also demonstrated in the HER application of these materials.<sup>33</sup> The equivalent pseudo-capacitance  $CPE_{ps}$  of MoS<sub>x</sub>/

GCNT/CP ( $157 \text{ F g}^{-1}$ ) was almost twice that of MoS<sub>x</sub>/carbon paper ( $80 \text{ F g}^{-1}$ ).

Beside a high capacitance, the electrochemical stability of supercapacitor electrode materials is also of great interest. The stability of the MoS<sub>x</sub>/GCNT/CP electrode was evaluated by a degradation test performed with 500 galvanostatic charge/discharge cycles at a high charge/discharge current density of  $5 \text{ A g}^{-1}$ . The degradation of the electrode discharge capacitance during the degradation test is reported in Fig. 7. Fig. 7 shows that the discharge capacitance of the electrode slowly degraded during the test with an 80% retention of capacitance after 500 charge/discharge cycles. It should be noted that the degradation test was performed at a high charge/discharge rate of  $5 \text{ A g}^{-1}$ . A high charge/discharge current can potentially degrade the electrode faster than a slow charge/discharge rate due to the quick ion insertion into and extraction from the electrode active materials. Capacitance degradation is commonly found in pseudo-capacitive active materials. Although further optimizations of the electrode will need to be pursued, we consider an 80% capacitance retention at a high charge/discharge rate of  $5 \text{ A g}^{-1}$  a good electrochemical stability demonstrated by the MoS<sub>x</sub>/GCNT/CP electrode.

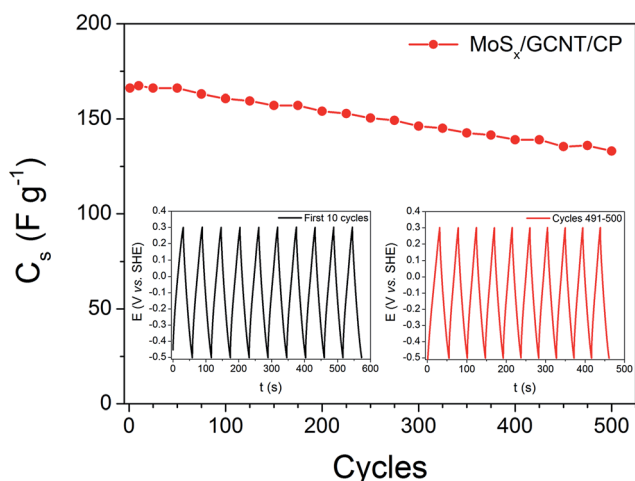


Fig. 7 Degradation test of the MoS<sub>x</sub>/GCNT/CP electrode performed with 500 charge/discharge cycles at  $5 \text{ A g}^{-1}$ , showing the degradation of electrode specific capacitance during the test, with (insets) plots of the first and last 10 charge/discharge cycles (time axes  $t$  are referenced to the beginning of each 10-cycle set).

## 4. Conclusions

In this work, we report the application of MoS<sub>x</sub> as the main active material for supercapacitor electrodes. MoS<sub>x</sub> was deposited onto a high surface area conductive electrode of GCNT/CP at room temperature. MoS<sub>x</sub> was successfully deposited on the GCNT hybrids and formed intimate contacts with the conductive GCNT/CP support. The MoS<sub>x</sub>/GCNT/CP composite electrode showed high specific capacitance even at high discharge rates. The deposition of MoS<sub>x</sub> on a conductive and high specific



surface area support demonstrated this to be an effective method to enhance the supercapacitive performance of MoS<sub>x</sub>. Together with the good electrochemical stability, the MoS<sub>x</sub>/GCNT/CP electrode was a promising electrode material candidate for supercapacitor applications.

## Acknowledgements

K. C. P., D. H. C. C. and A. T. S. W. acknowledge the support from National University of Singapore (NUS) (Grants number: R284-000-142-112, R284-000-120-281, and R-144-000-321-112). K. C. P. acknowledges NUS Graduate School for Integrative Sciences and Engineering for the NGS Scholarship. K. C. P. acknowledges Mr Wong How Kwong, Dr Zheng Minrui and Ms Pang Teng Jar for their assistance with XPS, Raman spectroscopy and XRD, respectively.

## References

- G. Wang, L. Zhang and J. Zhang, *Chem. Soc. Rev.*, 2012, **41**, 797–828.
- Y. Wang, Z. Shi, Y. Huang, Y. Ma, C. Wang, M. Chen and Y. Chen, *J. Phys. Chem. C*, 2009, **113**, 13103–13107.
- K.-J. Huang, L. Wang, J.-Z. Zhang, L.-L. Wang and Y.-P. Mo, *Energy*, 2014, **67**, 234–240.
- J. Gamby, P. L. Taberna, P. Simon, J. F. Fauvarque and M. Chesneau, *J. Power Sources*, 2001, **101**, 109–116.
- C. Liu, Z. Yu, D. Neff, A. Zhamu and B. Z. Jang, *Nano Lett.*, 2010, **10**, 4863–4868.
- E. Frackowiak, K. Metenier, V. Bertagna and F. Beguin, *Appl. Phys. Lett.*, 2000, **77**, 2421–2423.
- Y. Hou, Y. Cheng, T. Hobson and J. Liu, *Nano Lett.*, 2010, **10**, 2727–2733.
- H. Jiang, J. Ma and C. Li, *Adv. Mater.*, 2012, **24**, 4197–4202.
- R. R. Salunkhe, K. Jang, S.-w. Lee, S. Yu and H. Ahn, *J. Mater. Chem.*, 2012, **22**, 21630–21635.
- H. Jiang, T. Zhao, C. Li and J. Ma, *J. Mater. Chem.*, 2011, **21**, 3818–3823.
- S. Ratha and C. S. Rout, *ACS Appl. Mater. Interfaces*, 2013, **5**, 11427–11433.
- M. Acerce, D. Voiry and M. Chhowalla, *Nat. Nanotechnol.*, 2015, **10**, 313–318.
- B. Hu, X. Qin, A. M. Asiri, K. A. Alamry, A. O. Al-Youbi and X. Sun, *Electrochim. Acta*, 2013, **100**, 24–28.
- J. M. Soon and K. P. Loh, *Electrochem. Solid-State Lett.*, 2007, **10**, A250–A254.
- E. G. da Silveira Firmiano, A. C. Rabelo, C. J. Dalmaschio, A. N. Pinheiro, E. C. Pereira, W. H. Schreiner and E. R. Leite, *Adv. Energy Mater.*, 2014, **4**, DOI: 10.1002/aenm.201301380.
- G. Sun, X. Zhang, R. Lin, J. Yang, H. Zhang and P. Chen, *Angew. Chem., Int. Ed.*, 2015, **54**, 4651–4656.
- K.-J. Huang, L. Wang, Y.-J. Liu, Y.-M. Liu, H.-B. Wang, T. Gan and L.-L. Wang, *Int. J. Hydrogen Energy*, 2013, **38**, 14027–14034.
- A. Ramadoss, T. Kim, G.-S. Kim and S. J. Kim, *New J. Chem.*, 2014, **38**, 2379–2385.
- Y. Zhang, W. Sun, X. Rui, B. Li, H. T. Tan, G. Guo, S. Madhavi, Y. Zong and Q. Yan, *Small*, 2015, **11**, 3694–3702.
- K.-J. Huang, J.-Z. Zhang and J.-L. Cai, *Electrochim. Acta*, 2015, **180**, 770–777.
- X. Liu, J.-Z. Zhang, K.-J. Huang and P. Hao, *Chem. Eng. J.*, 2016, **302**, 437–445.
- K.-J. Huang, J.-Z. Zhang, Y.-L. Jia, K. Xing and Y.-M. Liu, *J. Alloys Compd.*, 2015, **641**, 119–126.
- K.-J. Huang, J.-Z. Zhang and Y. Fan, *J. Alloys Compd.*, 2015, **625**, 158–163.
- Y. Miki, D. Nakazato, H. Ikuta, T. Uchida and M. Wakihara, *J. Power Sources*, 1995, **54**, 508–510.
- M. Bouroushian, *Electrochemistry of Metal Chalcogenides*, Springer-Verlag Berlin Heidelberg, Berlin Heidelberg, 1st edn, 2010.
- M. Pumera, Z. Sofer and A. Ambrosi, *J. Mater. Chem. A*, 2014, **2**, 8981–8987.
- D. J. Li, U. N. Maiti, J. Lim, D. S. Choi, W. J. Lee, Y. Oh, G. Y. Lee and S. O. Kim, *Nano Lett.*, 2014, **14**, 1228–1233.
- J. D. Benck, Z. Chen, L. Y. Kuritzky, A. J. Forman and T. F. Jaramillo, *ACS Catal.*, 2012, **2**, 1916–1923.
- D. Merki, S. Fierro, H. Vrubel and X. Hu, *Chem. Sci.*, 2011, **2**, 1262–1267.
- C. G. Morales-Guio and X. Hu, *Acc. Chem. Res.*, 2014, **47**, 2671–2681.
- K.-C. Pham, D. H. C. Chua, D. S. McPhail and A. T. S. Wee, *ECS Electrochem. Lett.*, 2014, **3**, F37–F40.
- K.-C. Pham, D. S. McPhail, C. Mattevi, A. T. S. Wee and D. H. C. Chua, *J. Electrochem. Soc.*, 2016, **163**, F255–F263.
- K.-C. Pham, Y.-H. Chang, D. S. McPhail, C. Mattevi, A. T. S. Wee and D. H. C. Chua, *ACS Appl. Mater. Interfaces*, 2016, **8**, 5961–5971.
- K. C. Pham, NUS-ICL Joint Ph.D. (NGS) thesis, National University of Singapore, 2016.
- T. A. J. Loh, Y. Hu, K. C. Pham, Z. Tan and D. H. C. Chua, *IEEE 16th International Conference on Nanotechnology (IEEE-NANO)*, 2016, pp. 899–900.
- T. Weber, J. C. Muijsers and J. W. Niemantsverdriet, *J. Phys. Chem.*, 1995, **99**, 9194–9200.
- H. Vrubel and X. Hu, *ACS Catal.*, 2013, **3**, 2002–2011.
- C. H. Chang and S. S. Chan, *J. Catal.*, 1981, **72**, 139–148.
- P. D. Tran, T. V. Tran, M. Orio, S. Torelli, Q. D. Truong, K. Nayuki, Y. Sasaki, S. Y. Chiam, R. Yi, I. Honma, J. Barber and V. Artero, *Nat. Mater.*, 2016, **15**, 640–646.
- L. L. Zhang and X. S. Zhao, *Chem. Soc. Rev.*, 2009, **38**, 2520–2531.
- L. L. Zhang, R. Zhou and X. S. Zhao, *J. Mater. Chem.*, 2010, **20**, 5983–5992.
- C.-C. Hu, K.-H. Chang, M.-C. Lin and Y.-T. Wu, *Nano Lett.*, 2006, **6**, 2690–2695.
- R. K. Das, B. Liu, J. R. Reynolds and A. G. Rinzler, *Nano Lett.*, 2009, **9**, 677–683.
- L.-Q. Fan, G.-J. Liu, C.-Y. Zhang, J.-H. Wu and Y.-L. Wei, *Int. J. Hydrogen Energy*, 2015, **40**, 10150–10157.
- X. Zhou, B. Xu, Z. Lin, D. Shu and L. Ma, *J. Nanosci. Nanotechnol.*, 2014, **14**, 7250–7254.



- 46 J. Jiang, L. Zhang, X. Wang, N. Holm, K. Rajagopalan, F. Chen and S. Ma, *Electrochim. Acta*, 2013, **113**, 481–489.
- 47 X. Du, W. Zhao, Y. Wang, C. Wang, M. Chen, T. Qi, C. Hua and M. Ma, *Bioresour. Technol.*, 2013, **149**, 31–37.
- 48 A. Thambidurai, J. K. Lourdasamy, J. V. John and S. Ganesan, *Korean J. Chem. Eng.*, 2014, **31**, 268–275.
- 49 A. G. Pandolfo and A. F. Hollenkamp, *J. Power Sources*, 2006, **157**, 11–27.
- 50 S. Talapatra, S. Kar, S. K. Pal, R. Vajtai, L. Ci, P. Victor, M. M. Shaijumon, S. Kaur, O. Nalamasu and P. M. Ajayan, *Nat. Nanotechnol.*, 2006, **1**, 112–116.
- 51 M. D. Stoller, S. Park, Y. Zhu, J. An and R. S. Ruoff, *Nano Lett.*, 2008, **8**, 3498–3502.
- 52 J. P. Zheng, P. J. Cygan and T. R. Jow, *J. Electrochem. Soc.*, 1995, **142**, 2699–2703.
- 53 Y.-Z. Zheng, H.-Y. Ding and M.-L. Zhang, *Thin Solid Films*, 2008, **516**, 7381–7385.
- 54 J. P. Zheng and T. R. Jow, *J. Electrochem. Soc.*, 1995, **142**, L6–L8.
- 55 C.-C. Hu and T.-W. Tsou, *Electrochem. Commun.*, 2002, **4**, 105–109.
- 56 A. Zolfaghari, F. Ataherian, M. Ghaemi and A. Gholami, *Electrochim. Acta*, 2007, **52**, 2806–2814.
- 57 M. Ghaemi, F. Ataherian, A. Zolfaghari and S. M. Jafari, *Electrochim. Acta*, 2008, **53**, 4607–4614.
- 58 V. Khomenko, E. Frackowiak and F. Béguin, *Electrochim. Acta*, 2005, **50**, 2499–2506.
- 59 J. Wang, Y. Xu, X. Chen and X. Du, *J. Power Sources*, 2007, **163**, 1120–1125.
- 60 H. An, Y. Wang, X. Wang, L. Zheng, X. Wang, L. Yi, L. Bai and X. Zhang, *J. Power Sources*, 2010, **195**, 6964–6969.
- 61 Y. Fang, J. Liu, D. J. Yu, J. P. Wicksted, K. Kalkan, C. O. Topal, B. N. Flanders, J. Wu and J. Li, *J. Power Sources*, 2010, **195**, 674–679.
- 62 S. H. Mujawar, S. B. Ambade, T. Battumur, R. B. Ambade and S.-H. Lee, *Electrochim. Acta*, 2011, **56**, 4462–4466.
- 63 H. Zhang, G. Cao, Z. Wang, Y. Yang, Z. Shi and Z. Gu, *Electrochem. Commun.*, 2008, **10**, 1056–1059.

